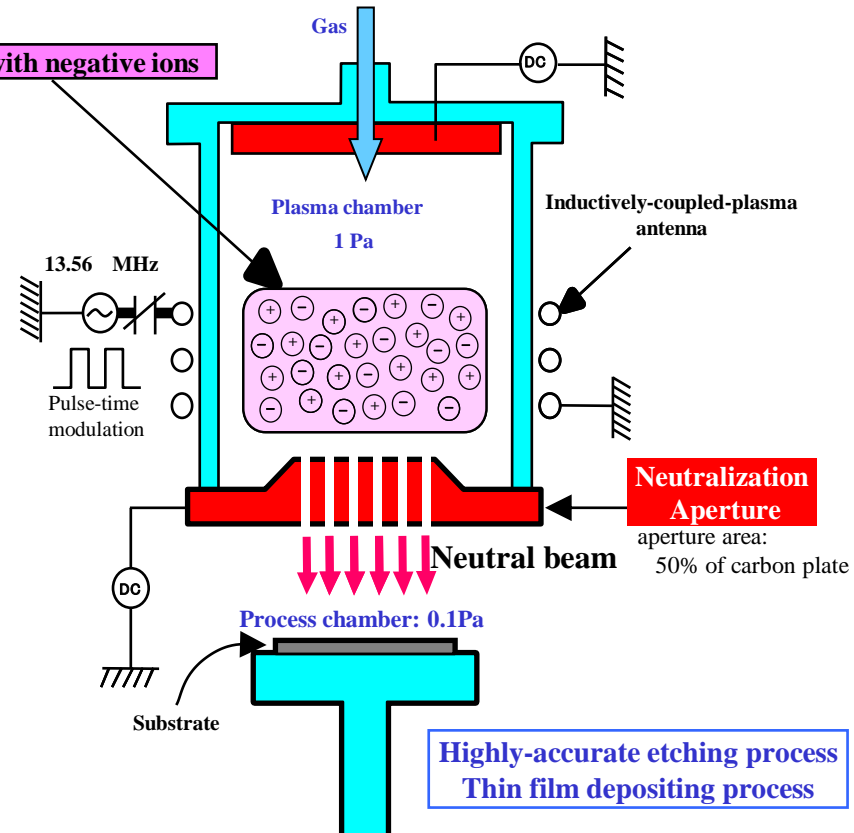
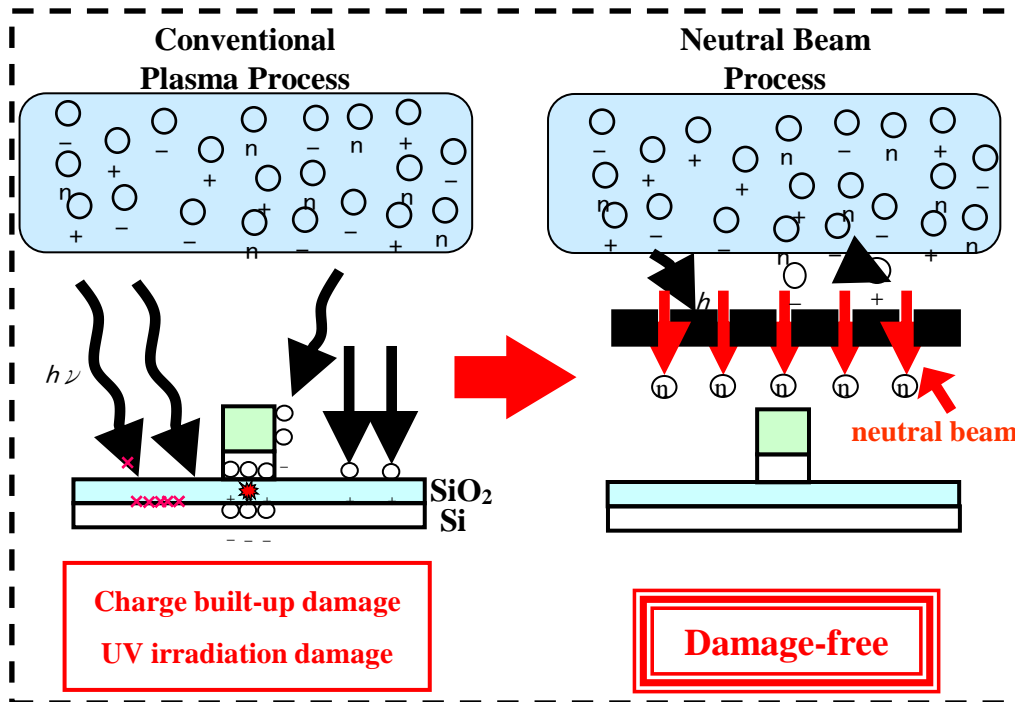


# Neutral Beam Technology

We are developing high efficient and low-energy neutral beam source. Our target is to control surface reaction with high rate and high selectivity by understanding reactivity of these particles.

**\* Highly efficient generation of low-energy neutral beam by using negative ions**

**\* Highly accurate etching Process**



- High density neutral beam (1mA/cm<sup>2</sup>~)
- Energy controllable (10eV~1keV)
- High neutralization efficiency (~100%)